

INFORMATION DISCLOSURE STATEMENT 37 C.F.R. § 1.97(b)		ATTORNEY DOCKET NO. 70020.0077USWO/10/586187
		U.S. APPLICATION SERIAL NO. NEW APPLICATION
		CONFIRMATION NO. N/A
		BASED ON INTERNATIONAL APPLICATION NO. PCT/JP2005/000346
INTERNATIONAL FILING DATE January 14, 2005		
INVENTOR(S) Toru KIMURA, et al.	EXAMINER Unassigned	GROUP ART UNIT N/A
TITLE OF APPLICATION UPPER LAYER FILM FORMING COMPOSITION FOR LIQUID IMMERSION AND METHOD OF FORMING PHOTORESIST PATTERN		

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

With regard to the above-identified application, the items of information listed on the enclosed Form 1449 are brought to the attention of the Examiner. All of the references listed were cited in an International Search Report mailed April 5, 2005.

This statement should be considered because it is submitted within three months of the filing date of the above-identified application, which is not an application under 37 C.F.R. § 1.53(d). Accordingly, no fee is due for consideration of the items listed on the enclosed Form 1449.

In accordance with 37 C.F.R. §1.98(a)(2), a copy of each document or other information listed on the enclosed Form 1449 is provided. Enclosed for the Examiner's information is a copy of the International Search Report.

No representation is made that a reference is "prior art" within the meaning of 35 U.S.C. §§ 102 and 103 and Applicants reserve the right, pursuant to 37 C.F.R. § 1.131 or otherwise, to establish that the reference(s) are not "prior art." Moreover, Applicants do not represent that a reference has been thoroughly reviewed or that any relevance of any portion of a reference is intended.

Consideration of the items listed is respectfully requested. Pursuant to the provisions of M.P.E.P. 609, it is requested that the Examiner return a copy of the attached

10/586187
JAP20 Rec'd PCT/PTO 14 JUL 2006

Form 1449, marked as being considered and initialed by the Examiner, to the
undersigned with the next official communication.

Please charge any additional fees or credit any overpayment to Deposit Account
No. 13-2725.

Respectfully submitted,

MERCHANT & COULLD, R.C.


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July 14, 2006

Date

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Patent & Trademark Office

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	A					

FOREIGN PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS							TRANSLATION	
		DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	YES	NO
	B	11-176727 A	07/02/1999	Japan			Abstract	
	C	06-12452 B2	02/16/1994	Japan				X
	D	10-104827 A	04/24/1998	Japan			Abstract	
	E	2004-325466	11/18/2004	Japan			Abstract	
	F	2004/079453 A1	09/16/2004	WIPO			Abstract	

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

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EXAMINER	DATE CONSIDERED
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EXAMINER: Initial if the reference is considered, whether or not the citation is in conformance with MPEP 609. Draw a line through the citation if it is not in conformance and it is not considered. Include a copy of this form with the next communication to the Applicant.